

*“Particle-in-cell/Monte Carlo collisions treatment of an Ar/O<sub>2</sub> magnetron discharge used for the reactive sputter deposition of TiO<sub>x</sub> films”.* Bultinck E, Bogaerts A, New journal of physics **11**, 103010 (2009). <http://doi.org/10.1088/1367-2630/11/10/103010>